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FORM*PTO 1449 (modified) U.S. DEPARTMENT OF COMMERCE			862.C2183	09/819,737						
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	F REFERENCES CITED BY A	1	Haruhiro ONO, et al.							
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Date Submitted to PTO: October 23, 2001			March 29, 2001 FEB 1 3 2003 E GROUP 2812. 2812.							
U.S. PATENT DOCUMENTS										
*EXAMINER	DOCUMENT NUMBER	R DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE				
INITIAL	5,834,783	11/10/1998	Muraki, et al.	250	398					
	5,864,142	01/26/1999	Muraki, et al.	250	491.1					
	5,905,267	05/18/1999	Muraki	250	492.22					
	5,981,954	11/09/1999	Muraki	250	397					
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	4,419,580	12/06/1983	Walker, et al.	250	396 R					
4			FOREIGN PATENT DOCUMENTS		T	TRANSLATION				
	DOCUMENT	DATE	COUNTRY	CLASS	SUBCLASS	YES/NO/ OR ABSTRACT				
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Sheet 1 of 2

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LIST OF	ATENT AND TRADEMARK OFF F REFERENCES CITED BY APPL (Use several sheets if necesser to PTO: October 23, 2001	ICANT(S)	APPLICANT Haruhiro ONO, et al.								
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